

**PATENT APPLICATION  
IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re application of  
Takako SUZUKI, et al.

Docket No: Q67844

Appln. No.: 10/084,204

Group Art Unit: 1752

Confirmation No.: 6177

Examiner: Unknown

Filed: February 28, 2002

For: POSITIVE PHOTORESIST COMPOSITION AND PROCESS FOR FORMING  
RESIST PATTERN USING SAME

**REQUEST FOR RECONSIDERATION UNDER 37 C.F.R. § 1.111**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

This Request for Reconsideration is submitted in response to the Office Action dated March 27, 2003. A Petition for a three month extension of time is being concurrently filed, making a response due on or before September 29, 2003 (September 27, 2003 being a Saturday). Please consider the remarks as submitted herewith on the accompanying pages.

**REMARKS**

Claims 1-4 and 6-20 are all the claims pending in the application.